

## GaAs PHEMT MMIC POWER AMPLIFIER, 0.2 - 22 GHz

### Typical Applications

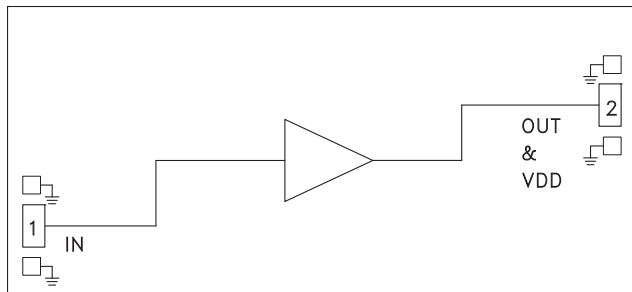
The HMC907 is ideal for:

- Test Instrumentation
- Microwave Radio & VSAT
- Military & Space
- Telecom Infrastructure
- Fiber Optics

### Features

- High P1dB Output Power: +27 dBm
- High Gain: 14 dB
- High Output IP3: +38 dBm
- Single Supply: +10V @ 350 mA
- 50 Ohm Matched Input/Output
- Die Size: 2.91 x 1.33 x 0.1 mm

### Functional Diagram



### General Description

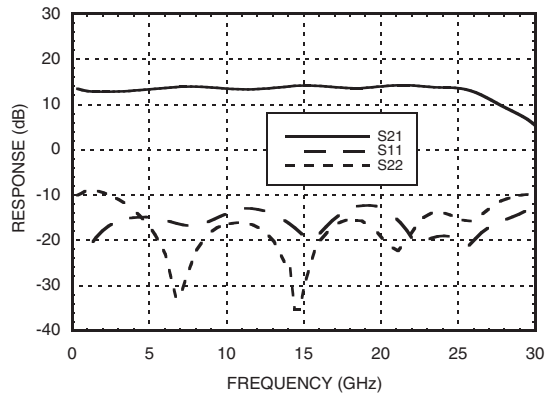
The HMC907 is a GaAs MMIC pHEMT Distributed Power Amplifier die which operates between 0.2 and 22 GHz. This self-biased power amplifier provides 14 dB of gain, 38 dBm output IP3 and +27 dBm of output power at 1 dB gain compression while requiring only 350mA from a +10V supply. Gain flatness is excellent at  $\pm 0.6$  dB from DC to 12 GHz making the HMC907 ideal for EW, ECM, Radar and test equipment applications. The HMC907 amplifier I/Os are internally matched to 50 Ohms facilitating integration into Multi-Chip-Modules (MCMs). All data is taken with the chip connected via two 0.025mm (1 mil) wire bonds of minimal 0.31 mm (12 mils) length.

### Electrical Specifications, $T_A = +25^\circ\text{C}$ , $V_{dd} = +10\text{V}$ , $I_{dd} = 350\text{mA}$

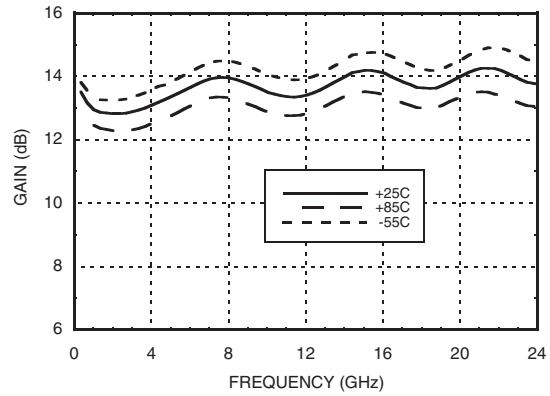
Parameter	Min.	Typ.	Max.	Min.	Typ.	Max.	Min.	Typ.	Max.	Units
Frequency Range	0.2 - 8			8 - 16			16 - 22			GHz
Gain	12	13.5		12	13.5		12.5	14		dB
Gain Flatness		$\pm 0.6$			$\pm 0.5$			$\pm 0.3$		dB
Gain Variation Over Temperature		0.008			0.008			0.009		dB/°C
Input Return Loss		15			15			15		dB
Output Return Loss		15			20			15		dB
Output Power for 1 dB Compression (P1dB)	23	26		25	27		23	25.5		dBm
Saturated Output Power (P <sub>sat</sub> )		28.5			29.5			28.5		dBm
Output Third Order Intercept (IP3)		37			38			37		dBm
Noise Figure		3.5			2.5			3.0		dB
Supply Current (I <sub>dd</sub> ) (V <sub>dd</sub> = 10V)		350			350			350		mA

**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

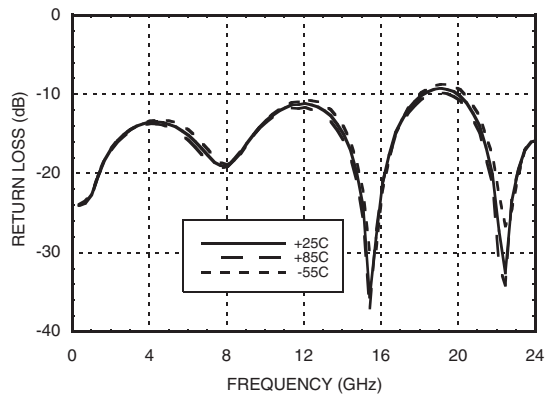
**Gain & Return Loss**



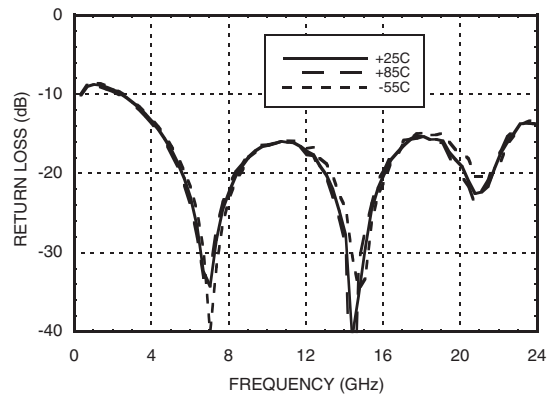
**Gain vs. Temperature**



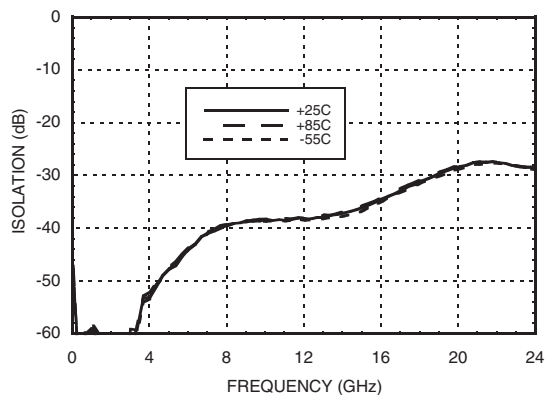
**Input Return Loss vs. Temperature**



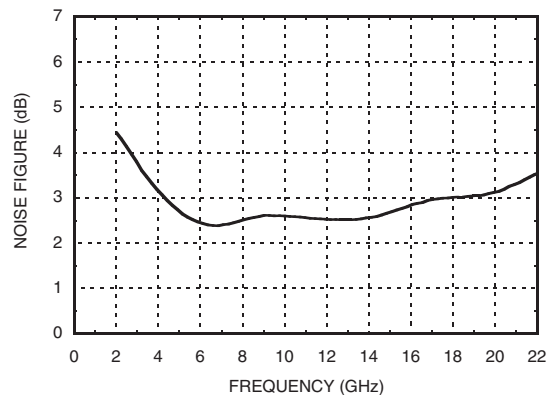
**Output Return Loss vs. Temperature**



**Reverse Isolation vs. Temperature**

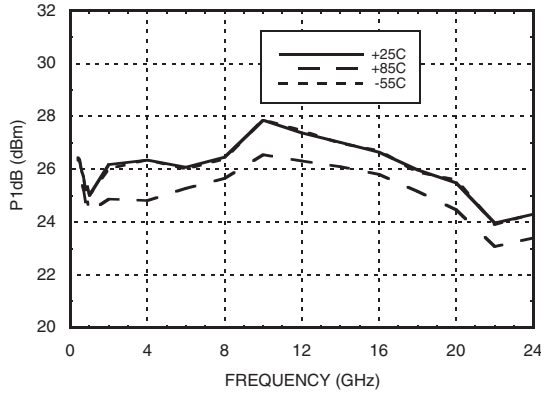


**Noise Figure vs. Frequency**

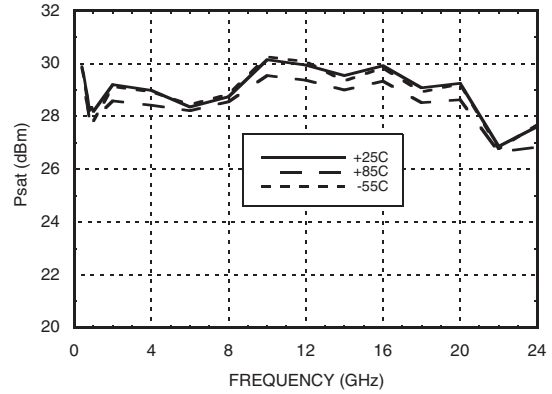


**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

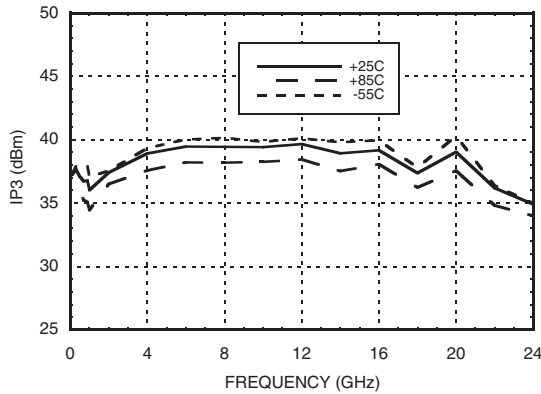
**P1dB vs. Frequency**



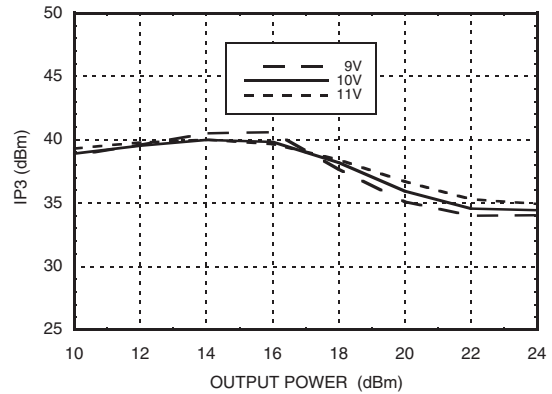
**Psat vs. Temperature**



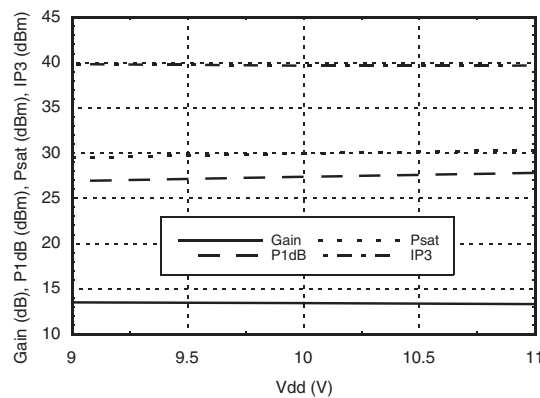
**Output IP3 vs. Temperature  
@ Pout = 16 dBm Tone**



**Output IP3 vs. Output Power @ 12 GHz**

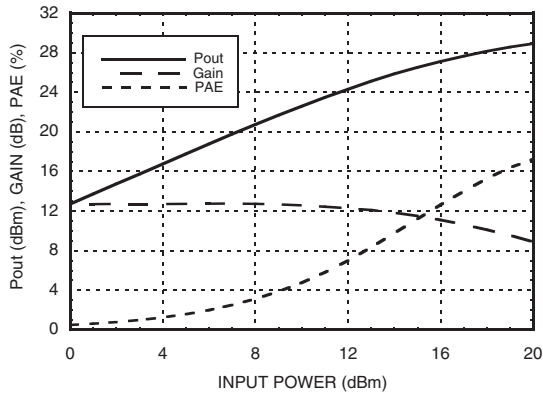


**Gain, Power & Output IP3 vs.  
Supply Voltage @ 12 GHz**

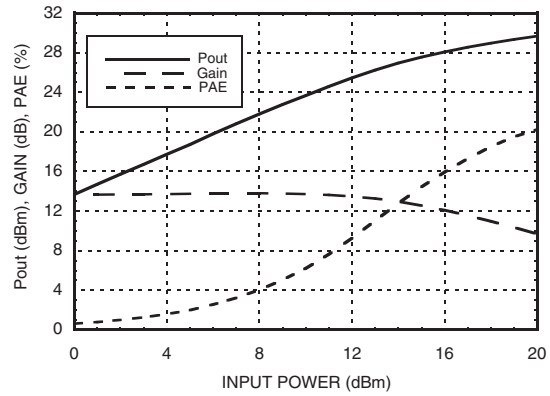


**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

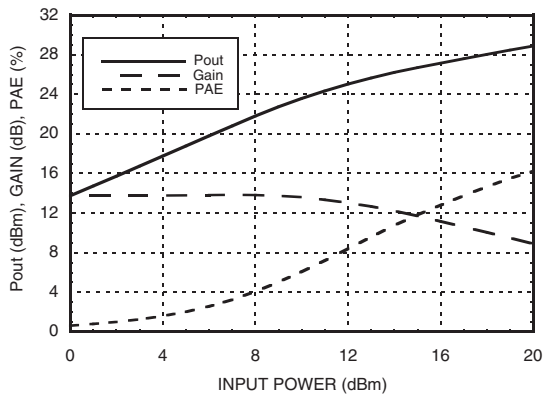
**Power Compression @ 2 GHz**



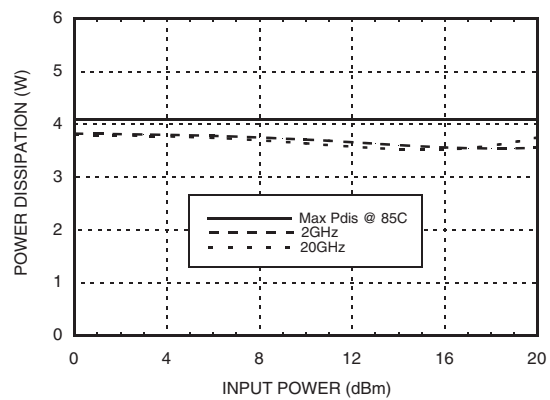
**Power Compression @ 12 GHz**



**Power Compression @ 20 GHz**



**Power Dissipation**



**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

**Absolute Maximum Ratings**

Drain Bias Voltage (Vdd)	+11 Vdc
RF Input Power (RFIN)(Vdd = +11V)	+20 dBm
Channel Temperature	150 °C
Continuous P <sub>diss</sub> (T= 85 °C) (derate 63 mW/°C above 85 °C)	4.1 W
Thermal Resistance (channel to die bottom)	15.8 °C/W
Storage Temperature	-65 to 150°C
Operating Temperature	-55 to 85 °C

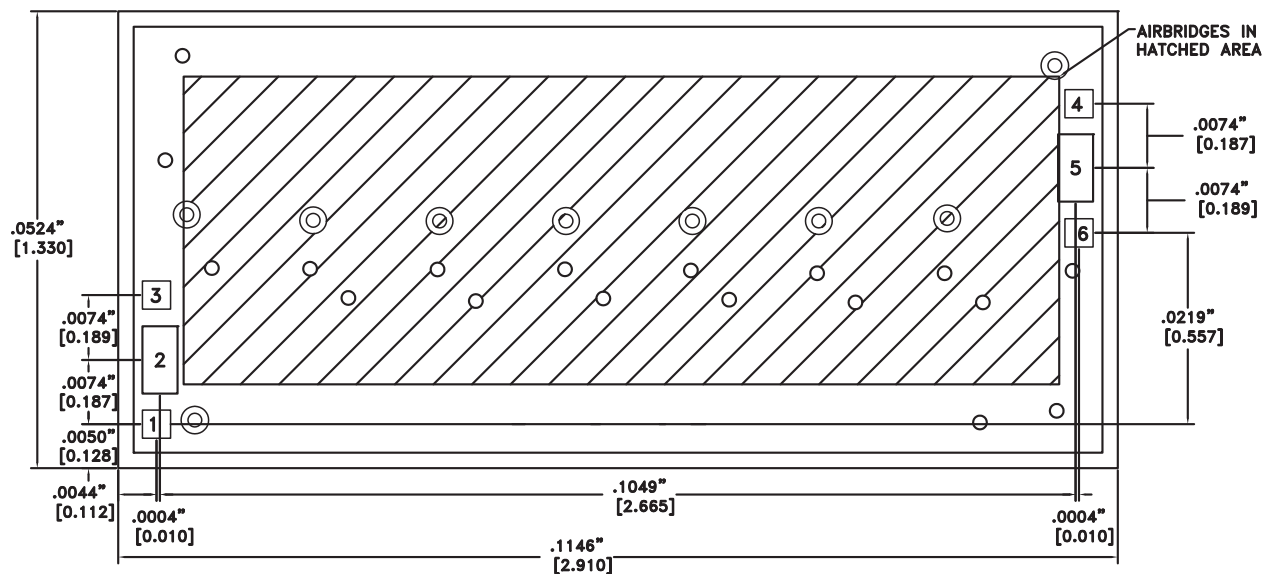
**Typical Supply Current vs. Vdd**

Vdd (V)	I <sub>dd</sub> (mA)
+9	350
+10	350
+11	350



**ELECTROSTATIC SENSITIVE DEVICE  
OBSERVE HANDLING PRECAUTIONS**

**Outline Drawing**



This die utilizes fragile air bridges. Any pick-up tools used must not contact the die in the cross hatched area.

**Die Packaging Information [1]**

Standard	Alternate
WP-9 (Waffle Pack)	[2]

[1] Refer to the "Packaging Information" section for die packaging dimensions.

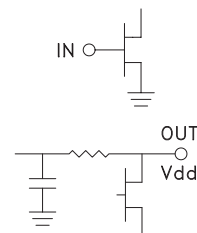

[2] For alternate packaging information contact Hittite Microwave Corporation.

**NOTES:**

1. ALL DIMENSIONS IN INCHES [MILLIMETERS]
2. DIE THICKNESS IS 0.004 (0.100)
3. TYPICAL BOND PAD IS 0.004 (0.100) SQUARE
4. BOND PAD METALLIZATION: GOLD
5. BACKSIDE METALLIZATION: GOLD
6. BACKSIDE METAL IS GROUND
7. NO CONNECTION REQUIRED FOR UNLABELED BOND PADS
8. OVERALL DIE SIZE IS ±.002

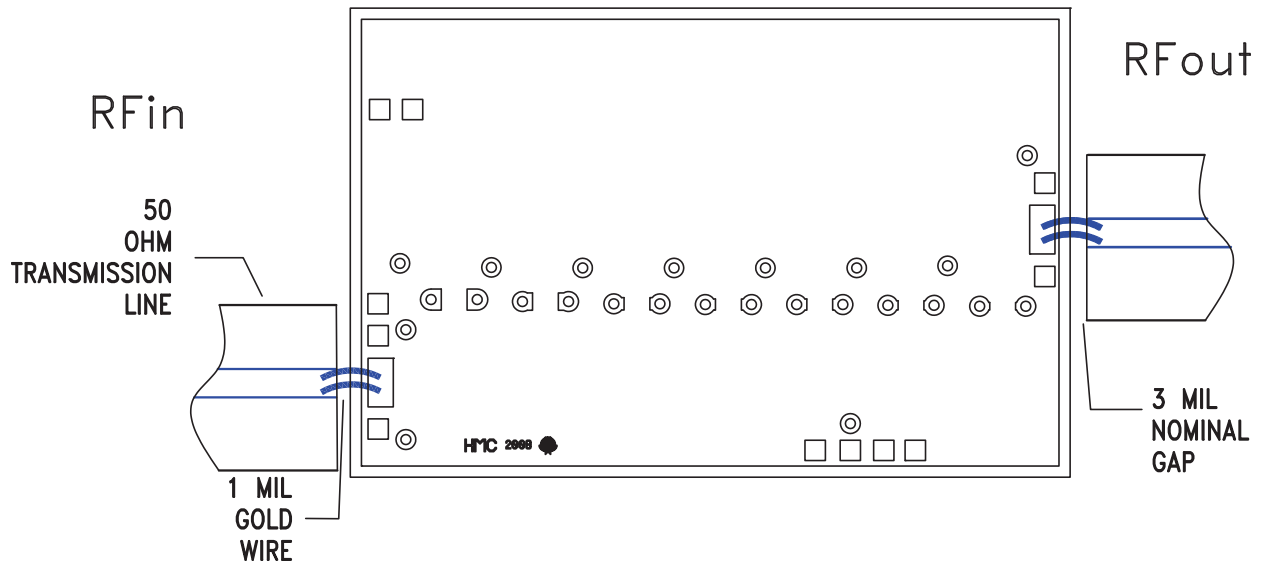
**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

**Pad Descriptions**

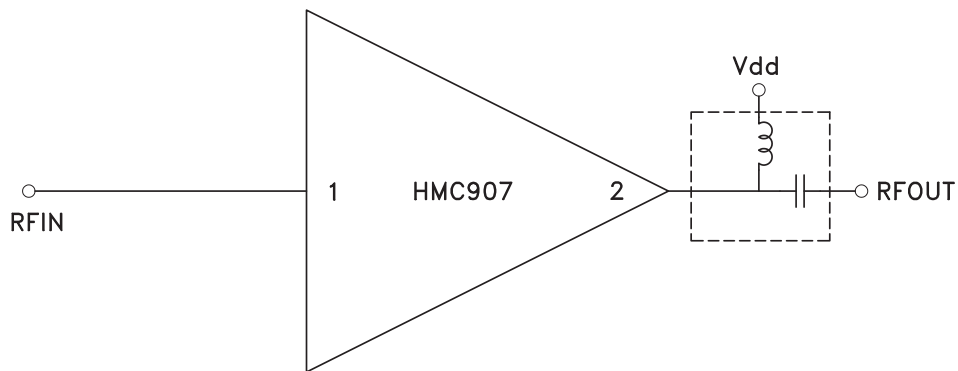
Pad Number	Function	Description	Interface Schematic
1	RFIN	This pad is DC coupled and matched to 50 Ohms. Blocking capacitor is required.	 <p>The schematic shows an input terminal labeled 'IN' connected to the gate of a PHEMT. The drain of the PHEMT is connected to an output terminal labeled 'OUT' and a DC bias network consisting of a resistor and a capacitor connected to 'Vdd'. The source of the PHEMT is connected to ground.</p>
2	OUT & Vdd	RF output for amplifier. Connect DC bias (Vdd) network to provide drain current (I <sub>dd</sub> ). See application circuit herein.	
Die Bottom	GND	Die bottom must be connected to RF/DC ground.	 <p>The schematic shows a terminal labeled 'GND' connected to ground.</p>

**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

**Assembly Diagram**



**Application Circuit**



*NOTE 1: Drain Bias (Vdd) must be applied through a broadband bias tee with low series resistance and capable of providing 500mA*

**GaAs PHEMT MMIC  
POWER AMPLIFIER, 0.2 - 22 GHz**

**Mounting & Bonding Techniques for Millimeterwave GaAs MMICs**

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be placed as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).

**Handling Precautions**

Follow these precautions to avoid permanent damage.

**Storage:** All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

**Cleanliness:** Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

**Static Sensitivity:** Follow ESD precautions to protect against ESD strikes.

**Transients:** Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

**General Handling:** Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

**Mounting**

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

**Eutectic Die Attach:** A 80/20 gold tin preform is recommended with a work surface temperature of 255 °C and a tool temperature of 265 °C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 °C. DO NOT expose the chip to a temperature greater than 320 °C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

**Epoxy Die Attach:** Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

**Wire Bonding**

RF bonds made with two 1 mil wires are recommended. These bonds should be thermosonically bonded with a force of 40-60 grams. DC bonds of 0.001" (0.025 mm) diameter, thermosonically bonded, are recommended. Ball bonds should be made with a force of 40-50 grams and wedge bonds at 18-22 grams. All bonds should be made with a nominal stage temperature of 150 °C. A minimum amount of ultrasonic energy should be applied to achieve reliable bonds. All bonds should be as short as possible, less than 12 mils (0.31 mm).

